



PRESS RELEASE

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Repeat order from IBM for a pattern generator for electronic packaging

Täby, Sweden, October 10, 2000 – Micronic Laser Systems AB (OM Stockholm Exchange: MICR), who is at the forefront in semiconductor and display laser pattern generators for the production of photomasks to the world wide electronic industries, is pleased to announce that we have received an order for a MP80+ laser pattern generator from IBM, USA. The system will be used for photomask production for electronic packaging applications. Delivery will take place during the first half year of 2001.

“This order strengthens our co-operation and form the basis for future business with IBM”, says Bert Jeppsson, President and CEO of Micronic Laser Systems AB.

The Micronic MP80+ combines the three most important properties of a multi purpose pattern generator for photomask production; leading edge quality, extremely high throughput and flexibility for different substrates, processes and applications. This makes it well suited for encoders and electronic packaging applications in virtually any mask shop environment.

About Micronic Laser Systems

Micronic Laser Systems is a Swedish high-tech company engaged in the development, manufacture and marketing of a series of extremely accurate laser pattern generators for the production of photomasks. The technology involved is known as microlithography. Micronic's systems are used by the world's leading electronics companies in the manufacture of television and computer displays, semiconductor circuits and semiconductor packaging components. Micronic is located in Täby, north of Stockholm and at present has subsidiaries in the United States and Japan and a service office in Taiwan. Micronic, with net sales of SEK 213 million (1999), has around 230 employees worldwide.